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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/620,605	07/17/2003	Qi Xiang	64965-168	9283
7590 12/14/2004			EXAMINER	
McDermott, Will & Emery			CRANE, SARA W	
600 13th Street, N.W. Washington, DC 20005-3096			ART UNIT	PAPER NUMBER
			2811	

Please find below and/or attached an Office communication concerning this application or proceeding.

		$\mathcal{M}_{\ell}$			
	Application No.	Applicant(s)			
	10/620,605	XIANG, QI			
Office Action Summary	Examiner	Art Unit			
	Sara W. Crane	2811			
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the c	orrespondence address			
A SHORTENED STATUTORY PERIOD FOR REPL' THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply if NO period for reply is specified above, the maximum statutory period versions to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be tin y within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from , cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).			
Status					
<ul> <li>1) ⊠ Responsive to communication(s) filed on 21 S</li> <li>2a) ☐ This action is FINAL. 2b) ⊠ This</li> <li>3) ☐ Since this application is in condition for alloward closed in accordance with the practice under E</li> </ul>	action is non-final.  nce except for formal matters, pro				
Disposition of Claims					
4) ⊠ Claim(s) 10-20 is/are pending in the applicatio 4a) Of the above claim(s) is/are withdray 5) □ Claim(s) is/are allowed. 6) ⊠ Claim(s) 1-12 and 15-20 is/are rejected. 7) ⊠ Claim(s) 13 and 14 is/are objected to. 8) □ Claim(s) are subject to restriction and/or	wn from consideration.				
Application Papers					
9)☐ The specification is objected to by the Examine	er.				
10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.					
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).  Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).					
Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Ex					
The part of declaration is objected to by the Ex	Carmiller. Note the attached Office	ACION OF IOINIA 10-102.			
Priority under 35 U.S.C. § 119	·				
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of:  1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority application from the International Burea * See the attached detailed Office action for a list	s have been received. s have been received in Applicat rity documents have been receive u (PCT Rule 17.2(a)).	ion No ed in this National Stage			
Attachment(s)  1) Notice of References Cited (PTO-892)	4) 🔲 Interview Summary	r (PTO-413)			
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	Paper No(s)/Mail D				

Application/Control Number: 10/620,605

Art Unit: 2811

## **DETAILED ACTION**

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 10-12 and 15-20 are rejected under 35 U.S.C. 103(a) as being unpatentable over Fitzergald.

With respect to claim 10, figures 13A and 13B of the reference show SiGe layer 1304 formed on a base layer (1306, 1308), and silicon layer 1302, 1314 formed on the SiGe layer. The silicon layer is selectively removed in first regions 1314. Implanting dopant and gate formation would have been obvious to form the desired transistors, as shown in for example figures 14A and 14B. With respect to claim 11, CMOS transistors would have been obvious to implement CMOS circuitry. With respect to claim 12, substantially all of layer 1314 is removed. With respect to claims 17-18, the thicknesses recited would have been obvious for gate oxidation (column 9, line 67) in order to allow for optimal gate control of the channel. With respect to claim 19, strained Si would have been obvious because the lattice mismatch to SiGe would cause strain. With respect to claim 20, figure 1 shows SiGe grading, where 1308 would be read as the SiGe layer of claim 10. (A portion of silicon layer 1306 is removed in the oxidation step as shown in figure 13D.)

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## Allowable Subject Matter

Claims 13-14 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to S. Crane, whose telephone number is (571) 272-1652.

The supervisor for Art Unit 2811, Eddie Lee can be reached on (571) 272-1732. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Sara W. Crane Primary Examiner Art Unit 2811

San V Crane